

Application Data Sheet

Application Information

Application Type::	Regular
Subject Matter::	Nationalization
Suggested Group Art Unit::	N/A
CD-ROM or CD-R?::	None
Sequence submission?::	None
Computer Readable Form (CRF)?::	No
Title::	PHASE SHIFT MASK, FABRICATION METHOD THEREOF, AND FABRICATION METHOD OF SEMICONDUCTOR APPARATUS
Request for Early Publication?::	No
Request for Non-Publication?::	No
Small Entity?::	No
Petition included?::	No
Secrecy Order in Parent Appl.?::	No

Applicant Information

Applicant Authority Type::	Inventor
Primary Citizenship Country::	Japan
Status::	Full Capacity
Given Name::	Minoru
Family Name::	Sugawara
City of Residence::	Kanagawa
Country of Residence::	Japan
Street of mailing address::	c/o Sony Coporation, 7-35, Kitashinagawa 6-chome Shinagawa-Ku

City of mailing address:: Tokyo
Country of mailing address:: Japan
Postal or Zip Code of mailing address:: 141-0001

Correspondence Information

Correspondence Customer Number:: 23353

Representative Information

Representative Customer Number:: 23353

Domestic Priority Information

Application:	Continuity Type::	Parent Application::	Parent Filing Date::
This Application	National Stage of	PCT/JP03/08377	07/01/2003

Foreign Priority Information

Country::	Application number::	Filing Date::	Priority Claimed::
Japan	P2002-193168	07/02/02	Yes
Japan	P2002-200777	07/10/02	Yes

Assignee Information

Assignee name:: Sony Corporation
Street of mailing address:: 6-7-35 Kitashinagawa
Shinagawa-Ku
City of mailing address:: Tokyo
Country of mailing address:: Japan
Postal or Zip Code of mailing address:: 141-0001